IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Hiroshi YAMADA et al.)) Group Art Unit: 1795
Application No.: 10/587,315)) Examiner: Vaughan II, Juan E. `
Filed: July 26, 2006))
For: PHOTOSENSITIVE RESIN COMPOSITION FOR LASER ENGRAVABLE PRINTING SUBSTRATE (as amended)) Confirmation No.: 4548))

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

REPLY TO NON-FINAL OFFICE ACTION

This reply is filed in response to the non-final action of March 21, 2008. A request for a two-month extension of time and the appropriate fee are being filed concurrently with this reply. Please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims in this paper.

Remarks/Arguments follow the amendment sections of this paper.